

IEUVI MASK TWG

October 2, 2008

Agenda

12:00 PM - 1:00 PM	Lunch	
1:00 PM - 1:10 PM	Welcome and Introduction	<i>K. Orvek, SEMATECH</i>
1:10 PM - 1:45 PM	Status Overview SEMI Standards - P37, Fiducials, Carrier	<i>K. Orvek, L. He, SEMATECH</i>
1:45 PM - 2:45 PM	Mask Readiness for 32nm Pilot Line, Users vs. Makers	<i>All</i>
2:45 PM - 3:05 PM	Break	
3:05 PM - 4:20 PM	Future Issues <ul style="list-style-type: none">• CTE- Mask Temperature: Scanner vs. Manufacture• Mask Incidence Angle Change, When Needed, Impact	<i>ASML and Nikon</i>
4:20 PM - 4:45 PM	Rank Top 10 Issues	<i>All</i>
4:45 PM - 5:00 PM	Wrap-Up Discussion and Next Meeting	<i>K. Orvek, SEMATECH</i>